

IRW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 6234**
Hideaki MATSUHASHI : Docket No. 2003-0859A
Serial No. 10/600,827 : Group Art Unit 2822
Filed June 23, 2003 : Examiner Ida M. Soward

SEMICONDUCTOR DEVICE FORMED
ON AN SOI STRUCTURE WITH A
STRESS-RELIEF LAYER

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated February 27, 2004, please amend the above-identified application as follows.